

	Type	L #	Hits	Search Text	DBs	Time Stamp	Comments
1	BRS	L1	7435	(chemical near mechanical near polishing or cmp) near25 (wiring or conduct\$3)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM TDB	2004/02/1 1 10:12	
2	BRS	L2	1	(chemical near mechanical near polishing or cmp) near25 (wiring or conduct\$3) near25 (polysilazane)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM TDB	2004/02/1 1 10:13	
3	BRS	L3	67	(chemical near mechanical near polishing or cmp) near25 (wiring or conduct\$3) near25 (spin near on near glass or sog)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM TDB	2004/02/1 1 10:19	
4	BRS	L4	597	(chemical near mechanical near polishing or cmp) near25 (spin near on near glass or sog)	USPA T; US-P GPUB ; EPO; JPO; DERW ENT; IBM TDB	2004/02/1 1 10:20	